

Proposal to the Senate Educational Policy Committee

PROPOSAL TITLE: Establish Graduate Concentration in Plasma Engineering within the Master of Engineering in Engineering Degree in the College of Engineering

SPONSOR: Rizwan Uddin, Department Head of Nuclear, Plasma and Radiological Engineering, 217-333-2295, rizwan@illinois.edu.

COLLEGE CONTACT: Harry Dankowicz, Associate Dean for Graduate, Professional and Online Programs, 217-244-1231, danko@illinois.edu

BRIEF DESCRIPTION:

This proposal seeks to establish a Concentration in Plasma Engineering in the Master of Engineering (MEng) in Engineering degree in the College of Engineering (CoE). This concentration is professionally oriented and aimed at providing students solid foundational knowledge in three major sub-areas: plasma processing, plasma systems, and fusion technology. Students in this concentration will develop interdisciplinary competence through elective enrollment in CoE courses supporting complementary disciplines that intersect plasma engineering, including materials science, semiconductor processing, chemical catalysis, plasma medicine, and energy systems.

This concentration will be housed in the Department of Nuclear, Plasma and Radiological Engineering (NPRE). The concentration will require 32 hours organized as follows:

- 16 credit hours of core coursework in NPRE (see Appendix A);
- 12 credit hours of elective coursework to be chosen in consultation with advisor;
- 4 credit hours of professional development; with
- at least 12 credit hours at the 500 level overall.

JUSTIFICATION:

The NPRE Department at Illinois has established robust MS and PhD programs focused on research in nuclear, plasma, and radiological engineering. Based on market research and feedback from alumni working at prominent companies such as Intel Corporation, LAM Research, IBM, and Applied Materials, NPRE has identified a need also for a professionally-oriented master's-level curriculum that focuses on plasma engineering principles that are missing in comparable curricula in mechanical and electrical engineering.

Plasmas find use in a variety of leading-edge industry applications, including: bioactive surface functionalization, enhancing photo-catalytic behavior, manufacturing of hard coatings, converting intermittent sustainable energy into fuels, and realizing efficient solid-state lighting. The production of semiconductor chips utilizes plasmas interacting with surfaces at every major step: lithography to make the pattern, etching to remove material, and deposition to fill the right material back in. The newest lithography systems use EUV light produced by a plasma rather

than a laser. In all lithography systems, the photo-resist is removed by plasma processing. Etching using plasmas has been the standard for years and heralded the advent of the personal computer when it replaced chemical etching. In deposition, plasma-enhanced chemical and physical vapor deposition are mainstays. All of these processes lie at the heart of making, running, and designing new "fabs" – yet very few scientists and engineers doing this work are Plasma Engineers, or even know much about plasmas. Major chip and semiconductor manufacturers hire electrical and mechanical engineers into positions where the use of plasmas impacts every stage of their job. Lack of proper preparation in plasma processing, vacuum technology, and plasma engineering principles results in the need for additional training and costly overhead. With increasing demand for shorter technology development time scales, hiring engineers with advanced training in plasma technology is highly desired.

Illinois is uniquely positioned to respond to the demand for Plasma Engineers. Indeed, there is no institution in the world with the curricular depth and breadth of the plasma engineering program at Illinois. This program also benefits from expertise and infrastructure sustained by state-of-theart research and innovation activities in NPRE across plasma science and engineering, including the HIDRA stellarator fusion facility, over 20 plasma-based processing devices, 3 major plasma surface-engineering facilities, and leading computational plasma-physics simulations tools and software for analyzing plasma-materials interactions.

The proposed professionally-oriented Concentration in Plasma Engineering will leverage the academic and research leadership of Illinois to prepare graduates to fill technical development and management roles in plasma-based industries. It relies on a core curriculum composed from existing courses and special-topics courses (498 or 598) that have been offered at least twice each, which have been proposed as new courses (see Appendix A). It further leverages a wealth of elective courses across the College of Engineering that build competence in complementary disciplines, including plasma medicine, semiconductor processing, control systems, computational plasma physics, surface materials science, astrophysics, plasma diagnostics, energy systems, materials by design, software development, data science, advanced materials characterization, and chemical processes.

BUDGETARY AND STAFF IMPLICATIONS:

1) Resources

a. How does the unit intend to financially support this proposal?

The unit is requesting self-supporting program status for this concentration. Students enrolled in this concentration will pay tuition. The College of Engineering will use some of the graduate tuition dollars returned to the college from the Office of the Vice Provost for Budget and Resource Planning to provide the NPRE department with resources needed to support the proposed curriculum. Graduate tuition funds returned to the college from campus are considered state, recurring funds that may be used to fund faculty and lecturer salaries, support instruction, or at the discretion of the NPRE Department Head in a manner consistent with campus policy.

b. How will the unit create capacity or surplus to appropriately resource this program? If applicable, what functions or programs will the unit no longer support to create capacity?

The proposed curriculum is composed from existing courses and three new courses that were previously offered as special-topics courses (NPRE 498 or 598). Existing capacity and controlled enrollments will ensure the overall quality of experience for students in the program. No changes are necessary to existing functions or programs.

c. Will the unit need to seek campus or other external resources? If so, please provide a summary of the sources and an indication of the approved support.

No campus or other external funding sources are needed. Resources made available by campus to support growth in professionally-oriented master's programs, as well as tuition resources will be sufficient to develop and offer the program.

d. Please provide a letter of acknowledgment from the college that outlines the financial arrangements for the proposed program.

The submission of this proposal by the College of Engineering will verify the financial arrangement in answer 1a, above. See attached MOU in Appendix C.

2) **Resource Implications**

a. Please address the impact on faculty resources including the changes in numbers of faculty, class size, teaching loads, student-faculty ratios, etc.

The proposed program will not adversely impact faculty resources or the student-tofaculty ratio. In fact, NPRE has added three faculty members in the past five years with expertise in plasma engineering as part of a strategic alignment of research and education. Moreover, NPRE created three new courses to support this program, which all three have been taught twice previously as either NPRE 498 or 598. Existing faculty resources are therefore adequate for servicing the increased demand on plasma engineering courses anticipated through this program. Tuition revenues will fund additional teaching assistant and teaching faculty support as necessary.

b. Please address the impact on course enrollment in other units and provide an explanation of discussions with representatives of those units.

It is anticipated that enrollment in the Concentration in Plasma Engineering will ramp up to an average of 20-25 students in the first three years of the program, with a longterm steady-state of 30-40 students per year. Students enrolled in this concentration will have a large range of options available to fulfill the elective course requirement, implying minimal impact on enrollments in courses offered by units outside NPRE.

c. Please address the impact on the University Library.

See attached letter from the Library.

d. Please address the impact on technology and space (e.g. computer use, laboratory use, equipment, etc.)

No impact on research labs as this is a non-research master's program. The lab space

in NPRE that is used for the required core course, NPRE 423, has the ability to add sections to accommodate the additional enrollment. The remaining coursework does not require lab space. In addition, the College of Engineering has ample engineering workstations to accommodate the resources that are needed for this program.

For new degree programs only:

3) Briefly describe how this program will support the University's mission, focus, and/or current priorities. Include specific objectives and measurable outcomes that demonstrate the program's consistency with and centrality to that mission.

The proposed concentration will position the University as a unique destination for prospective students interested in a professionally-oriented curriculum in plasma engineering. It will also attract attention of employers from across the public, private, and nongovernment sectors who will be engaged as part of a deliberate effort to develop internship and career opportunities for program students and graduates. By its nature, the proposed concentration is consistent with campus priorities that emphasize cooperation among multiple disciplines. Finally, as an element of a revenue-generation strategy, the proposed concentration will provide resources for enhancing scholarship and educational opportunity also outside its disciplinary focus. Measurable outcomes include meeting enrollment, graduation, and placement objectives, but also indirect effects on the hiring of Plasma Engineers, as well as external funding for research and educational innovation at the nexus of plasmas for use across many cutting-edge technologies.

4) Please provide an analysis of the market demand for this degree program. What market indicators are driving this proposal? What type of employment outlook should these graduates expect? What resources will be provided to assist students with job placement?

There is clear demand for Plasma Engineers to meet the needs of the semi-conductor industry, as well as across a range of application areas in medicine, energy production, and advanced manufacturing. NPRE PhD and MS students with a focus in plasma engineering typically graduate with multiple job offers. Several companies fund NPRE plasma science and engineering research explicitly for the opportunity to get to know our students and potentially employ them. Indeed, feedback from the companies who want to hire our graduates, e.g., Intel Corporation and Tokyo Electron Ltd, is an important driver in the creation of the proposed professionally-oriented Concentration in Plasma Engineering.

At the same time, peer US institutions offer at most limited exposure to plasma engineering. Plasma-based research at Michigan, Princeton, Wisconsin, and North Carolina State result in about 1-2 courses offered in the subject of plasma engineering. Plasma physics courses are available in select physics, electrical engineering, and aerospace engineering programs in the US, in support of related research. Worldwide, there are a few master's-level programs with similar coverage; in Plasma Surface Engineering at Sheffield Hallam University and in Plasma Science at Ecole Polytechnique Federale de Lausanne. Neither has the scope of course offerings and related infrastructure that are available at Illinois. Another program is the Plasma Engineering at TU Eindhoven in the Netherlands. This program is affiliated with the Dutch Institute for Fundamental Energy Research (DIFFER) where several of the NPRE plasma faculty have significant collaboration. The program has several plasma-related courses.

To assist students with job placement, NPRE faculty and staff will work closely with Engineering Career Services and staff from the College of Engineering Center for Professional and Executive Training and Education. This will include realizing opportunities for internships (ENG 572) and capstone project (ENG 573) experiences that will put students in direct contact with potential employers.

5) If this is a proposed graduate program, please discuss the programs intended use of waivers. If the program is dependent on waivers, how will the unit compensate for lost tuition revenue?

Self-supporting status will be requested for this concentration, i.e., students under this program code will not be eligible for tuition waivers. This will be a fast-paced, 1-year professionally-oriented master's degree.

DESIRED EFFECTIVE DATE: Fall 2019

STATEMENT FOR PROGRAMS OF STUDY CATALOG: See Appendix B

CLEARANCES: (Clearances should include signatures and dates of approval. These signatures must appear on a separate sheet. If multiple departments or colleges are sponsoring the proposal, please add the appropriate signature lines below.)

Signatures:

Ripson

Unit Representative:

College Representative:

October 19 2018 Date:

<u> 12 - 12 - 18</u> Date:

Date:

Graduate College Representative:

Council on Teacher Education Representative:

Date:

Page 6 of 13

Appendix A: Proposed Concentration in Plasma Engineering

Concentration Degree Requirements

Program Component	Hours
 Core Courses NPRE 421, Plasma and Fusion Science (3 hours) NPRE 423, Plasma Laboratory (2 hour) NPRE 429, Plasma Engineering (3 hours) NPRE 527, Plasma Technology of Gaseous Electronics (4 hours) 	16
 In addition, must complete one of the following courses: NPRE 481, Writing on Technology and Security (4 hours) ENG 573, Capstone Project (4 hours) NPRE 523, Plasma Waves (4 hours) NPRE 526, Plasma-Material Interactions (4 hours) 	
Elective Courses to be selected with approval of an advisor in areas relevant to Plasma Engineering such as material science, semiconductor processing, plasma medicine, and energy systems.	
Professional Development Courses from approved list	
Total Hours	
Minimum of 12 hours of the 500-level courses required for the degree, with a minimum of 8 500-level credit hours in NPRE.	<u>I</u>

NOTE: NPRE has submitted three new course proposals for the following core courses:

- NPRE 523, Plasma Waves. This course has been taught twice as NPRE 598 in Fall 2014 (Plasma Waves & Heating Tech) and Fall 2017 (Plasma Waves & Heating Tech).
- NPRE 526: Plasma-Material Interactions. This course has been taught twice as NPRE 598 in Spring 2016 (Fund Plasma Matls Interactions) and Spring 2018 (Fund Plasma Matls Interactions).
- NPRE 527: Plasma Technology of Gaseous Electronics. This course has been taught twice as NPRE 498 in Spring 2015 (Fusion Device operations) and Fall 2016 (Fusion Device operations). As the content for this course is finalized, the name of the course may be tweaked.

Approved list of Professional Development Courses

Students must complete a minimum of 4 hours from the list below:

- NPRE 597, Independent Study (project-based with advisor approval)
- ENG 572, Professional Practicum (external internship)
- ENG 573, Capstone Project (additional 4 hours of a large project if not completed in core requirement)
- TE 461, Technology Entrepreneurship
- TE 565, Technology Innovation & Strategy
- Other advisor-approved business-oriented or leadership courses

College of Engineering

engineering.illinois.edu

Harry Dankowicz Associate Dean for Graduate, Professional, and Online Programs 400 Engineering Hall 1308 West Green Street Urbana, Illinois 61801 217-244-1231 E-mail: danko@illinois.edu

Major: Engineering Degrees Offered: Master of Engineering Graduate Concentration: Plasma Engineering

Graduate Degree Programs

The College of Engineering offers a professionally-oriented Master of Engineering (MEng) degree program for students whose primary intent is a career in industry or government. This degree differs from the Master of Science degree in that it is a terminal degree and not a pathway to a doctoral program. The major in Engineering for the MEng degree requires the selection of an interdisciplinary concentration.

Admission

Students with bachelor's or master's degrees in engineering or related fields will be considered for admission if they have a grade point average of at least 3.00 (A = 4.00) for the last two years of undergraduate study. Admission is possible for the spring term, but most admissions are for the fall term. Full details of admission requirements are on the web page of the department offering the concentration.

All applicants whose native language is not English must submit a minimum TOEFL score of 103 (iBT), 257 (CBT), or 613 (PBT); or minimum International English Language Testing System (IELTS) academic exam scores of 7.0 overall and 6.0 in all subsections. Applicants may be exempt from the TOEFL if certain criteria are met (see

<u>https://grad.illinois.edu/admissions/instructions/04c</u> for exemptions). Full admission status is granted for those meeting the minimum requirements and having taken the TOEFL or IELTS, since the scores required for admission to the MEng program are above the minimum scores demonstrating an acceptable level of English language proficiency.

Master of Engineering in Engineering with a Concentration in Plasma Engineering

Degree Requirements

Code

Core Courses

Hours

16

- NPRE 421, Plasma and Fusion Science (3 hours)
- NPRE 423, Plasma Laboratory (2 hour)
- NPRE 429, Plasma Engineering (3 hours)
- NPRE 527, Plasma Technology of Gaseous Electronics (4 hours)

Code	Hours
Must complete one of the following courses:	
 NPRE 481, Writing on Technology and Security (4 hours) ENG 573, Capstone Project (4 hours) NPRE 523, Plasma Waves (4 hours) NPRE 526, Plasma-Material Interactions (4 hours) 	
Elective Courses to be selected with approval of an advisor in areas relevant to Plasma Engineering such as material science, semiconductor processing, plasma medicine, and energy systems.	
Professional Development Courses from approved list	4
Professional Development Courses from approved list Total Hours	32
Total Hours	
Total Hours Other Requirements and Conditions (may overlap):	32
Total Hours Total Hours Ther Requirements and Conditions (may overlap): Requirement A minimum of 20 credit hours must be taken from the University of Illinois Urbana-	32
Total Hours Total Hours Ther Requirements and Conditions (may overlap): Requirement A minimum of 20 credit hours must be taken from the University of Illinois Urbana- Champaign campus. A minimum of 12 500-level credit hours required for the concentration, with a	32

* For additional details and requirements, please refer to the web page of the degree's home unit and the Graduate College Handbook.

Appendix C: MOU Agreement

MEMORANDUM OF UNDERSTANDING BETWEEN THE

COLLEGE OF ENGINEERING (CoE)

AND THE

DEPARTMENT OF NUCLEAR, PLASMA, AND RADIOLOGICAL ENGINEERING (NPRE)

For the distribution of tuition funds for tuition-generating enrollments in a Professional Master's Degree Program

This MOU applies to tuition paying MEng in Engineering with a concentration in Plasma Engineering students in the NPRE Department and establishes a formula for the transfer of tuition funds between the CoE and NPRE. This is a new agreement, which follows the CoE Guidance Document for Professional Master's Program Tuition ratified in July, 2014. This agreement is not applicable to online programs or enrollments.

- For tuition generated by NPRE self-supporting MEng students, net tuition funds (those returned to CoE from campus minus applicable costs for the CoE Center for Professional and Executive Training and Education) will be split as follows
 - 20% CoE
 - 80% NPRE

Using the Campus Budget Office's report on net tuition received, tuition as non-recurring funds will be distributed to NPRE at the end of each fiscal year. This agreement is effective August 16, 2019 (or term the program is approved) and valid through August 15, 2022, assuming no future changes to the campus budget model.

Signatures:

Harry Daulean

10/19/2018

Date

by Harry Dankowicz Associate Dean for Graduate, Professional and Online Programs

10/19/2018

by Rizwan Uddin Head, Department of Nuclear, Plasma and Radiological Engineering Date

Appendix D: Classification

The G	raduate College Unive	rsity of Illinois at Urbana-Champaign
an and the second second second second		I FOR PROGRAM CLASSIFICATION DRTING or REIMBURSABLE
CURRENT PROGRAMS: Current graduate programs supporting.	can request a change in classifica	ation to Traditional or Reimbursable, but not to Self-
NEW PROGRAMS: New programs seeking Tra	ditional classification do not need t	to complete this form.
 a) Students enrolled There is no mecha supporting program significant problen b) Self-supporting star qualified for a part status makes the status c) Because Tradition Reimbursable class 	anism within the Human Resource m student to an assistantship. The ns result for everyone involved. atus results in reduced flexibility fo icular assistantship appointment a student ineligible. Ial, Reimbursable and Self-support	be aware of the following: leligible to hold waiver-generating appointments. NOTE: s Front End system that restricts the appointment of a Self refore, if a unit (faculty or staff) appoints a student, in error r the program. Even if a student in the program is most and financing is available through the program, the program ting programs each yield 90% of net tuition, and the hove, a program might find the Reimbursable classification
Please contact the Fellowsl or gradfellowships@illinois.	edu.	if you have questions or seek clarifications, (217) 333-003
IS THIS A NEW OR EXIST √New Program	ING PROGRAM:	
✓ New Program Existing Program	ING PROGRAM: Program Code:	
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1) Describe the reasons for this request and explain: (a) the pros and cons of the classification requested, and (b) how the requested classification will benefit and not adversely affect the academic quality of the program.

- (a) The proposed concentration is not a research-oriented program. It is designed so that it can be completed in two or three semesters in order to address an academic training gap at a professional level. The requested classification enhances the educational experience of students and employability of graduates who, after attaining a BS degree in engineering or equivalent field, will benefit from the differentiated value provided by this advanced professional degree. The requested classification is not expected to adversely impact recruitment of students interested in a research-oriented track with a traditional tuition model, nor significantly limit the potential pool of prospective students to the professionally-oriented track.
- (b) The requested classification will provide revenue streams that create new opportunities for the College of Engineering and NPRE to support strategic faculty recruitment and new academic initiatives within the area of plasma engineering, as well as across other relevant disciplines, thereby strengthening our scholarly impact and leadership.

2) Describe the expected impact of the requested classification to new students. How will these measures affect the affordability of the program? What type of financial aid, if any, will be offered? Note: Continuing students will not be affected as they are subject to the rules in effect at the time of their admission.

This is a new program. No change that would affect any current or future students in the existing MS and PhD degree programs is proposed. All students entering this new MEng concentration will need to pay tuition. We will not offer financial aid to any students who are enrolled in this MEng program.

3) What provisions will be made to communicate the implications of the classification to prospective and newly admitted students?

The self-supporting classification will be clearly explained on the program's website and in any and all communications to prospective students

4) Name the college and program contact persons in charge of implementing and communicating the classification and its consequences to students.

This is a new concentration within the MEng in Engineering degree. No changes in classification are being requested for any existing program. Professor J.P. Allain, NPRE Associate Head of Graduate Programs, and the Coordinator of MEng Programs for NPRE will be responsible for communicating the self-supporting classification and its consequences to prospective students. Additional College of Engineering contacts for this program are Professor Harry Dankowicz, Associate Dean for Graduate, Online and Professional Programs, and Rhonda McElroy, Executive Director of Engineering Graduate Programs.

From: "Uddin, Rizwan" <rizwan@illinois.edu>
Date: Friday, October 19, 2018 at 12:52 PM
To: Rhonda McElroy <rmcelroy@illinois.edu>
Cc: "Dankowicz, Harry" <danko@illinois.edu>, "Allain, Jean Paul"
<allain@illinois.edu>
Subject: Re: Masters of Engineering in Plasma Engineering

Hi Rhonda,

NPRE faculty today unanimously approved the proposal for the MEng concentration under the MEng degree in Engineering.

Rizwan

UNIVERSITY OF ILLINOIS AT URBANA-CHAMPAIGN

University Library Office of University Librarian and Dean of Libraries 230 Main Library, MC-522 1408 West Gregory Drive Urbana, IL 61801



November 1, 2018

Rhonda McElroy Director of Graduate and Professional Programs College of Engineering @ ILLINOIS Engineering Hall 405 1308 West Green Street Urbana, IL 61801

Dear Rhonda:

Thank you for providing the University Library with the opportunity to review the College of Engineering's proposals to the Senate's Committee on Educational Policy. The proposal to establish a MEng in Engineering with a Concentration in Plasma Engineering and the proposal to establish a MEng in Bioengineering with a concentration in Pharmaceutical Engineering were reviewed by several librarians that provide support for engineering and the biomedical sciences. They believe that the Library is well-positioned to support.

The University Library and the College of Engineering have a long history of working closely together. We look forward to utilizing the resources committed in order to grow in the areas necessary to provide support for this program.

Sincerely,

John P. Wilkin Juanita J. and Robert E. Simpson Dean of Libraries and University Librarian

c: Bill Mischo Thomas Teper



COLLEGE OF ENGINEERING

Office of the Dean 306 Engineering Hall, MC-266 1308 W. Green St. Urbana, IL 61801

December 12, 2018

Allison McKinney Graduate College 204 Coble Hall MC-322

Via: Rashid Bashir, Engineering College

Dear Allison,

The College of Engineering Executive Committee has reviewed and approved the following program revision. We now submit for campus approval.

"Establish Graduate Concentration in Plasma Engineering within the Master of Engineering in Engineering Degree in the College of Engineering"

Attached is a copy of the request.

Sincerely yours,

Henrique Rei

Henrique Reis, Vice Chair Executive Committee

Approval Recommended:

Rashid Bashir, Dean College of Engineering

December 12, 2018 Date

Harry Dankowicz Rhonda McElroy Henrique Reis

UNIVERSITY OF ILLINOIS AT URBANA-CHAMPAIGN

217.333.2150 • engineering.illinois.edu



Senate Educational Policy Committee Proposal Check Sheet

PROPOSAL TITLE (Same as on proposal): <u>Establish Graduate Concentration in Plasma Engineering</u> within the Master of Engineering in Engineering Degree in the College of Engineering

PROPOSAL TYPE (select all that apply below):

- A. Proposal for a NEW or REVISED degree program. Please consult the Programs of Study Catalog for official titles of existing degree programs.
 - 1. Degree program level:

	Graduate Professional Undergraduate						
2.	Proposal for a new degree (e.g. B.S., M.A. or Ph.D.):						
	Degree name, "e.g., Bachelor of Arts or Master of Science":						
3.	Proposal for a new or revised major, concentration, or minor :						
	New or Revised Major in (name of existing or proposed major):						
	New or Revised Concentration in (name of existing or proposed concentration):						
	Concentration in Plasma Engineering						
	New or Revised Minor in (name of existing or proposed minor):						
4.	Proposal to rename an existing major, concentration, or minor:						
	Major Concentration Minor						
	Current name:						
	Proposed new name:						
5.	Proposal to terminate an existing degree, major, concentration, or minor:						
	Degree Major Concentration Minor						
	Name of existing degree, major, or concentration:						
6.	Proposal involving a multi-institutional degree:						

	New	Revision	Termination			
	Name of existing Illinois (UIUC) degree:					
	Name of non-Illinois partnering institution:					
	Location of non-Illinois partnering institution:					
	State of Illinois	US State:	Foreign country:			
	roposal to create a new nit):	v academic unit (college,	school, department, program or other academic			
N	lame of proposed new	unit:				
C. Proposal to rename an existing academic unit (college, school, department, or other academic unit):						
C	Current name of unit: _					
Р	roposed new name of	unit:				
D. Proposal to reorganize existing units (colleges, schools, departments, or program):						
 Proposal to change the status of an existing and approved unit (e.g. change from a program to department) 						
	Name of current uni	t including status:				
2.	Proposal to transfer	an existing unit:				
	Current unit's name and home:					
	Proposed new home	for the unit:				
3.	Proposal to merge tw	vo or more existing units	(e.g., merge department A with department B):			
	Name and college of	f unit one to be merged:				
	Name and college of	f unit two to be merged:				
	Proposed name and	college of new (merged)	unit:			
4.	Proposal to terminat	e an existing unit:				
	Current unit's name	and status:				
E. 🗌 C	Other educational pol	icy proposals (e.g., acad	emic calendar, grading policies, etc.)			

Nature of the proposal: _____